Special Issue

Graphene-Based Photocatalysts for Water Decontamination

Message from the Guest Editors

This Special Issue welcomes manuscripts (original research papers, reviews or communications) covering all aspects of heterogeneous and homogeneous photocatalytic processes and applications for the degradation of organic pollutants and disinfection in water and wastewater, with a particular interest in graphene/ hybrid graphene materials. Submissions are welcome in, but are not limited to, the following areas:

- The development of a novel graphene hybrid for the photocatalytic remediation of wastewaters, including their preparation and characterizations;
- The photocatalytic degradation of emerging contaminants in wastewater;
- Scale-up approaches for photocatalytic degradation systems.

Guest Editors

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Deadline for manuscript submissions

closed (29 November 2024)



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Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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